

SEMICONDUCTOR-NANOCRYSTAL/CONJUGATED POLYMER THIN FILMS

CROSS-REFERENCES TO RELATED APPLICATIONS

5 This application is a non-provisional application based on U.S. Provisional Patent Application Nos. 60/365,401, filed March 19, 2002; 60/381,660, filed May 17, 2002 and 60/381,667, also filed on May 17, 2002. These U.S. Provisional Patent Applications are herein incorporated by reference in their entirety for all purposes. Copending U.S. patent applications are U.S. Serial Number 10/301,510, filed November 20, 2002, which claims
10 priority to U.S. Serial Number 60/335,435, filed November 30, 2001; and U.S. Serial Number 10/280,135, which claims priority to U.S. Serial Number 60/395,064, filed July 12, 2002 and 60/346,253, filed October 24, 2001. The contents of both utility applications and all provisional applications are incorporated by reference in their entirety for all purposes.

15 STATEMENT AS TO RIGHTS TO INVENTIONS MADE UNDER FEDERALLY SPONSORED RESEARCH OR DEVELOPMENT

 The invention described and claimed herein was made in part utilizing funds supplied by the United States Department of Energy under contract NO. DE-AC03-76SF000-
98 between the United States Department of Energy and The Regents of the University of
20 California. The government has certain rights to the invention.

BACKGROUND OF THE INVENTION

 The first solar cells were fabricated in the mid 1950s from crystalline silicon wafers. At that time, the most efficient devices converted 6% of solar power to electricity.

25 Advancements in solar cell technology over the past 50 years have resulted in the most efficient Si cell at 25% and commercial Si modules, an array of cells, at 10%. Although Si, in crystalline and polycrystalline forms, is the most common type of material used in solar cells, other semiconductors such as gallium arsenide, indium phosphide and cadmium telluride are being investigated for the next generation of higher efficiency solar cells. In
30 particular, high efficiency structures such as tandem cells, in which multiple band gaps are

layered in a single device, using GaInP, GaAs and Ge have attained record efficiencies of 34%.

Despite these impressive efficiencies, the high cost of manufacturing solar cells of the prior art limits their widespread use as a source of power. The construction of prior art commercial silicon solar cells involves four main processes: the growth of the semiconductor material, separation into wafers, formation of the device and its junctions, and encapsulation. For the cell fabrication alone, thirteen steps are required to make the solar cell and of these thirteen steps, five require high temperatures (300°C-1000°C), high vacuum or both. In addition, the growth of the semiconductor from a melt is at temperatures above 1400°C under an inert argon atmosphere. To obtain high efficiency devices (>10%), structures involving concentrator systems to focus sunlight on to the device, multiple semiconductors and quantum wells to absorb more light, or higher performance semiconductors such as GaAs and InP, are needed. The gain in performance results in increased manufacturing costs, which stem from the multiplication of the number of fabrication steps. To date, these high performance architectures have been employed mainly for extra-terrestrial applications such as in space shuttles and satellites, where efficiency per unit weight is as important as fabrication costs.

Another problem with the solar devices of the prior art is the high cost of manufacturing materials. The amount of silicon needed for 1kW of module output power is approximately 20kg. At \$20/kg, the material costs for electronic grade silicon is partially subsidized by the chip manufacturing sector. Other materials such as GaAs, which are synthesized with highly toxic gases, are a factor of 20 higher in cost at \$400/kg. Because solar cells are large area devices, such material costs hinder the production of inexpensive cells. As a result, thin film devices, which have active layers several microns thick of amorphous Si, CdTe, and CuInSe₂ are being explored. In 1991, O'Regan *et al.* reported the invention of a novel photochemical solar cell comprised of inexpensive TiO₂ nanocrystals and organic dye, O'Regan *et al. Nature* 353, 737 (1991).

Bilayer devices, from spin casting a derivative of polythiophene on which a layer of C₆₀ is evaporated, have been able to reach a maximum external quantum efficiency (EQE) of 23%. Higher efficiencies at 50% were obtained from blending derivatives of C₆₀ and MEH-PPV into a homogeneous film for a single-layer device. Further improvements in efficiencies are limited by the poor electron transport properties of C₆₀, which is characterized by hopping, and the low overlap between the device absorption and the solar emission spectrum, Greenham. N.C. *et al., Phys Rev. B*, Vol. 54, No. 24, Dec 1996.

It has been suggested previously to use CdSe particles in poly(3-hexylthiophene), see Alivisatos et al. *Adv. Mater.* **1999**, 11, No. 11. This work only teaches the use of nanocrystals less than 13 nm in size and the devices produced do not approach the efficiencies of those of the instant invention. Further, this prior art admits solution chemistry problems with nanorods and offers no solutions to the problems solved by the invention described herein. Solar cells based on inorganic nanorods according to the instant invention, which have good transport properties and absorption spectra that can also be extended into the near infrared, can potentially reach efficiencies that rival conventional solar cells based on bulk inorganic semiconductors. It is the thin films incorporating semiconductor-nanocrystals according to the embodiments of this invention that provide solutions to the above stated problems.

SUMMARY OF THE INVENTION

The invention described herein provides for thin films and methods of making comprising inorganic semiconductor-nanocrystals dispersed in semiconducting-polymers in high loading amounts. The invention also describes photovoltaic devices incorporating the thin films.

BRIEF DESCRIPTION OF THE DRAWINGS

FIG 1 shows an energy level diagram for CdSe and P3HT which shows a schematic of process of charge transfer between 5nm CdSe and P3HT..

FIG 2 shows a schematic of the structure of a nanorod-polymer blend photovoltaic device according to one embodiment of the invention.

FIG 3 shows a low resolution TEM image of a) 7 nm by 7 nm, b) 8 nm by 13 nm, c) 3 nm by 60 nm, and d) 7 nm by 60 nm CdSe nanocrystals

FIG 4 shows a AFM-TM topography image of a film consisting of 90 wt. % 7 nm by 7 nm CdSe nanocrystals dispersed in P3HT, spin cast from chloroform. The scan area is 5 μm .

FIG 5 shows a AFM-TM a) topography and b) phase images of films consisting of 90 wt. % 9 nm by 13 nm CdSe nanocrystals dispersed in P3HT spin cast from 1 vol. % and 8 vol. % pyridine in chloroform. Images are presented at the same scale for a scan area of 5 μm .

FIG 6 shows surface roughness (open circles) of films consisting of 90 wt. % 9 nm by 13 nm CdSe nanocrystals dispersed in P3HT spin cast from various concentrations of pyridine in chloroform. The maximum EQE (solid diamonds) is shown of devices made from these films. Lines serve as a guide to the eye.

FIG 7a shows a normalized photocurrent spectra for a 90 wt. % 3 nm by 60 nm CdSe nanorods in P3HT device (open circles) and after annealing at 120°C (solid squares).

FIG 7b shows the ratio of the EQE before and after heat treatment as a function of wavelength for 90 wt. % 3 nm by 60 nm CdSe nanorods in P3HT device and a nanorod-only device. The inset shows the individual 1-transmission spectra for 3 nm by 60 nm CdSe and P3HT.

FIG 8 shows the relative contribution of P3HT to the absorption (solid diamond, dashed line), photocurrent (open circle, solid line) and photocurrent after 120°C heat treatment (solid square, dashed line) of series of 3 nm by 60 nm nanorod devices in P3HT at various nanorod concentrations.

FIG 9 shows the EQE of 90 wt. % 7 nm by 14 nm CdSe in P3HT under ~ 0.1 mW/cm² illumination at 515 nm. The inset shows the PL efficiency of 60 wt. % 7 nm by 14 nm CdSe in P3HT samples under 514 nm excitation after heat treatment at various temperatures.

FIG 10 shows the EQE spectra of a 90 wt. % 7 nm by 60 nm CdSe nanorods in P3HT (open circles) and after 120 °C heat treatment (solid squares). Inset: the corresponding current-voltage characteristics, under illumination of 0.1 mW/cm² at 515 nm, for this device, which includes an open circuit voltage of 0.4 V and a fill factor of 0.5.

FIG 11a shows the EQE spectra of devices from 90 wt. % 7 nm by 60 nm CdSe nanorods in P3HT with thickness 212 nm, 271 nm and 346 nm before 120°C heat treatment.

FIG 11b shows the EQE spectra of devices from 90 wt. % 7 nm by 60 nm CdSe nanorods in P3HT with thickness 212 nm, 271 nm and 346 nm after 120°C heat treatment.

FIG 12a shows the relative enhancement of the EQE before and after heating at 120 °C for devices in FIG 11a and 11b.

FIG 12b shows the absolute difference in EQE before and after heat treatment.

FIG 13a shows a TEM of a thin film of 20 wt. % 3nm by 60nm CdSe nanorods and P3HT spin cast from chloroform.

FIG 13b shows a TEM of the same nanocrystals of FIG 13a when cast from a 10 vol.% pyridine in chloroform solution.

FIG 14 shows a TEM of a cross section of a 100 nm film consisting of 60 wt. % 10nm by 10nm CdSe nanocrystals in P3HT

FIG 15a shows a 7nm by 60nm CdSe nanorods.

FIG 15b shows a TEM of a cross section of a 100nm film consisting of 40 wt. %
5 CdSe nanorods in P3HT.

FIG 16 shows as the length of a 7nm diameter nanorod is increased successively from 7nm to 30nm and to 60nm, the EQE for the 90 wt. % CdSe in P3HT devices, rises by almost a factor of 3 to 54%, under illumination of 0.084mW/cm^2 at 515nm.

FIG 17a-c shows a TEM of 7 nm diameter nanocrystals with lengths, a) 7nm, b) 30nm
10 and c) 60nm. The scale bar is 50nm and all TEMs are at the same scale.

FIG 18 shows a the EQE for the 90 wt. % 3nm by 100nm branched CdSe nanorods in P3HT devices as a function of pyridine concentration.

FIG 19a shows tetrapod nanocrystals unaligned.

FIG 19b shows tetrapod nanocrystals aligned.

FIG 20 shows the EQE spectra for a series of 90 wt. % 7 nm by 60 nm CdSe in P3HT
15 devices with different film thicknesses.

FIG 21a shows the EQE spectra for 90 wt. % 7 nm by 7 nm CdSe in P3HT at various film thicknesses.

FIG 21b shows the corresponding absorption spectra for these devices, shown as a
20 function of increasing thickness.

FIG 22a shows a TEM of 40 wt% 5 nm CdSe nanocrystals in P3HT for TOPO treated nanocrystals.

FIG 22b shows a TEM of 40 wt% 5 nm CdSe nanocrystals in P3HT for T1 treated nanocrystals.

FIG 22^c shows a TEM of 40 wt% 5 nm CdSe nanocrystals in P3HT for pyridine
25 treated nanocrystals.

FIG 23a shows the I-V characteristics for 90 wt. % 7 nm by 60 nm CdSe nanorods in P3HT under 0.1mW/cm^2 illumination at 515nm.

FIG 23b shows the solar cell characteristics of the same FIG 23a device, measured
30 with a simulated AM 1.5 Global light source, include a short-circuit current of 5.7mA/cm^2 , a FF of 0.42, and an open-circuit voltage of 0.67V to yield a solar power conversion efficiency of 1.7%.

FIG 24 shows both the ideal and a typical I-V curve found experimentally.

DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENTS

In one embodiment of the invention there is disclosed a thin film comprising a semiconducting conjugated polymer having at least 5 wt% semiconductor-nanocrystals embedded therein.

In another embodiment there is disclosed a photovoltaic device comprising the thin film of this invention.

In another embodiment of this invention there is disclosed a process of making a polymeric thin film comprising washing surfactant coated semiconductor-nanocrystals with a solvent at least one time, and codissolving the washed semiconductor-nanocrystals and a semiconducting polymer in a binary solvent mixture, and depositing the mixture.

In another embodiment of the invention there is disclosed process of making a photoactive thin film comprising dispersing semiconductor-nanocrystals having an aspect ratio of greater than 2 in a semiconducting conjugated polymer to provide a polymer-nanocrystal composite, and depositing a thin film of said composite, such that the nanocrystals are embedded in the polymer at greater than 5 wt%.

In another embodiment of the invention there is disclosed a photovoltaic device, comprising a conjugated conductive polymeric layer having semiconductor-nanocrystals dispersed therein where the device has an power conversion efficiency greater than 1% at AM 1.5 global illumination.

In another embodiment of the invention there is disclosed a photovoltaic device comprising a first planar electrode, a thin film comprising a semiconducting conjugated polymer having semiconductor-nanocrystals embedded therein, the thin film being deposited on the first planar electrode, and a second electrode opposite the first electrode, and a hole injecting layer disposed between the thin film polymeric layer and the first planar electrode.

In preferred embodiments of this invention the semiconductor-nanocrystals will have an aspect ratio of greater than 2, preferably greater than 5, more preferably between about 5 and 50. Most preferred is about 10.

In preferred embodiments of this invention there is disclosed the dispersion or embedding of semiconductor-nanocrystals in the semiconducting-polymer. Preferably this "loading" is on the amount of greater than 5 wt%. More preferably, this amount is between 20 and about 95 wt%. Even more preferably the amount is between 50 and about 95 wt%. Most preferably the amount is about 90 wt%.

In preferred embodiments of this invention the semiconducting polymer will be a polymer or blend chosen from trans-polyacetylenes, polypyrroles, polythiophenes, polyanilines, poly(p-phenylene)s and poly(p-phenylene-vinylene)s, polyfluorenes, polyaromatic amines, poly(thienylene-vinylene)s and soluble derivatives thereof. Preferred
5 are (poly(2-methoxy5-(2'-ethylhexyloxy)p-phenylenevinylene) (MEH-PPV) and poly(3-hexylthiophene, (P3HT), with P3HT being the most preferred.

In preferred embodiments, the semiconductor-nanocrystals comprise rods having lengths greater than about 20 nm. More preferred are rods having a length of between 20 and 200 nm. Even more preferred are rods having lengths of between about 60 and 110 nm.

10 In more preferred embodiments the invention discloses the use of Group II-VI, Group III-V, Group IV semiconductors and tertiary chalcopyrites. More preferred are CdSe, CdTe, InP, GaAs, CuInS₂, CuInSe₂, AlGaAs, InGaAs, Ge and Si, and even more preferred is CdSe.

It is preferred that the semiconductor nanocrystals be branched nanocrystals. More preferred nanocrystals having 4 arms and tetrahedral symmetry.

15 It is preferred that the thin film of this invention have a thickness of about 200nm.

It is preferred that the process for making the thin film of this invention use a binary solvent mixture where at least one of the solvents is chosen from the group consisting pyridine, chloroform, toluene, xylenes, hexanes, water, dichlorobenzene, methylene chloride, an alkylamine, where the alkyl chain may be branched or unbranched and is between 2 and
20 20 carbons in length, butanol, methanol and isopropanol. Most preferred is pyridine in chloroform.

It is preferred that the binary solvent mixture be in an amount of between 1-15 vol%, with a more preferred range being 4-12 vol %, and most preferred is 8 vol%.

In another embodiment of the invention described herein there is disclosed a method
25 for making polymeric thin films having incorporated therein semiconductor nanocrystals where there is a step of washing the surfactant coated semiconductor nanocrystals at least once with a solvent, preferred in pyridine.

In another embodiment of the invention described herein is a method for making a polymeric thin film comprising thermal annealing of the deposited film at a temperature of
30 from 60 °C to about 200 °C. Preferred is about 120 °C.

In another embodiment of the invention there is disclosed herein a photovoltaic device incorporating a PEDOT:PSS (poly(ethylene-dioxy)thiophene:poly(styrene sulphonic acid)) hole transporting layer on top of an ITO electrode.

By "semiconductor-nanocrystal" it is meant to include semiconducting crystalline particles of all shapes and sizes. Preferably, they have at least one dimension less than about 100 nanometers, but they are not so limited. Rods may be of any length. "Nanocrystal", "nanorod" and "nanoparticle" can and are used interchangeably herein. In some embodiments of the invention, the nanocrystal particles may have two or more dimensions that are less than about 100 nanometers. The nanocrystals may be core/shell type or core type. For example, some branched nanocrystal particles according to some embodiments of the invention can have arms that have aspect ratios greater than about 1. In other embodiments, the arms can have aspect ratios greater than about 5, and in some cases, greater than about 10, etc. The widths of the arms may be less than about 200, 100, and even 50 nanometers in some embodiments. For instance, in an exemplary tetrapod with a core and four arms, the core can have a diameter from about 3 to about 4 nanometers, and each arm can have a length of from about 4 to about 50, 100, 200, 500, and even greater than about 1000 nanometers. Of course, the tetrapods and other nanocrystal particles described herein can have other suitable dimensions. In embodiments of the invention, the nanocrystal particles may be single crystalline or polycrystalline in nature. The invention also contemplates using nanorods of CdSe and CdTe that have aspect ratios above 20, even up to 50, and lengths greater than 100 nm, formed according to processes described in the literature, see Peng, X.G. et al. *Nature* **404**, 59 (2000) and Peng, Z.A. et al. *J. Am. Chem Soc.* **123**, 183 (2001).

The length of semiconductor-nanocrystal rods used herein have lengths between 20 and 200 nm. In preferred embodiments, the semiconductor-nanocrystals comprise rods having lengths greater than about 20 nm. More preferred are rods having a length of between 20 and 200 nm. Even more preferred are rods having lengths of between about 60 and 110 nm.

By "at least a portion of the semiconductor-nanocrystals have an aspect ratio greater than about 2" it is meant that if the semiconductor-nanocrystals are unbranched rods, then at least part of the total amount of the rods will have an aspect ratio of greater than about 2. The amount could be as high as 100%. Also, this means that if the nanocrystals are branched semiconductor-nanocrystals (which of course includes tetrapods), then "at least a portion" means that at least one branch has an aspect ratio of greater than 2. Aspect ratio is defined as the length of the longest dimension of a rod divided by its diameter. In the case of a branched nanocrystal, the aspect ratio for the branched nanocrystal is defined as the length of the longest branch divided by the longest branches diameter.

By "a portion of the semiconductor-nanocrystals are branched nanocrystals" it is meant that at least 1% by weight of the nanocrystals are branched nanocrystals. It is understood that the language "a portion" as defined herein could also include 100%, i.e. the "whole portion".

5 Although CdSe and CdTe semiconductor- nanocrystals are preferred, the nanocrystal particles may comprise other suitable semiconductor material, and be a rod, a shaped particle or a sphere. For example, the particles may comprise semiconductors such as compound semiconductors. Suitable compound semiconductors include Group II-VI semiconducting compounds such as MgS, MgSe, MgTe, CaS, CaSe, CaTe, SrS, SrSe, SrTe,
10 BaS, BaSe, BaTe, ZnS, ZnSe, ZnTe, CdS, CdSe, CdTe, HgS, HgSe, and HgTe. Other suitable compound semiconductors include Group III-V semiconductors such as GaAs, GaP, GaAs-P, GaSb, InAs, InP, InSb, AlAs, AlP, AlGaAs, InGaAs and AlSb. The use of Group IV semiconductors such as germanium or silicon may also be feasible under certain conditions. In other embodiments, the particles may comprise a dielectric material such as
15 SiC, SiN or any other material that can exhibit polytypism. Also included are the tertiary chalcopyrites, for example CuInS₂ and CuInSe₂. Some metals such as Fe, Ni, Cu, Ag, Au, Pd, Pt, Co and others may also exhibit polytypism and can be used in embodiments Rod, Arrow, Teardrop and tetrapod shaped semiconductor nanocrystals are defined in Manna et al. *J. Am. Chem. Soc.* **2000**, 12, 12700-12706, the contents of which are hereby incorporated by
20 reference for all purposes.

The nanocrystal particles according to embodiments of the invention can have unique optical, electrical, magnetic, catalytic, and mechanical properties, and can be used in a number of suitable end applications. They can be used, for example, as fillers in composite materials, as catalysts, as functional elements in optical devices, as functional elements in
25 photovoltaic devices (*e.g.*, solar cells), as functional elements in electrical devices, etc.

By "P3HT" it is meant poly(3-hexylthiophene), which includes regioregular P3HT, which includes head to head and also head to tail regioregular P3HT. Preferred is head to tail P3HT.

This invention contemplates that any semiconducting conjugated polymers that can be
30 processed from solution will function in accordance with this invention. By "semiconducting polymer" it is meant all polymers that have a pi-electron system. Non-limiting examples include trans-polyacetylene, polypyrrole, polythiophene, polyaniline, poly(p-phenylene and poly(p-phenylene-vinylene), polyfluorenes, polyaromatic amines, poly(thienylene-vinylene)s and soluble derivatives of the above. An example is (poly(2-methoxy,5-(2'-ethylhexyloxy)p-

phenylenevinylene) (MEH-PPV) and poly(3-alkylthiophene). Especially preferred is poly(3-hexylthiophene), P3HT. This invention also contemplates using conjugated polymers that are either solution processable or melt processable because of bulk pendant groups attached to the main conjugated chain or by its inclusion of the conjugated polymer into a copolymer structure of which one or more components are non-conjugated. Non-limiting examples include poly(4'-diphenylenediphenylvinylene), poly(1,4-phenylene-1-phenylvinylene and poly(1,4-phenylenediphenylvinylene, poly(3-alkylpyrrole) and poly(2,5-dialkoxy-p-phenylenevinylene). It is understood that by semiconducting conjugated polymer this could mean a mixture or blend of polymers, one of which is to be a semiconducting conjugated polymer. Thus the nanocrystals are or would be embedded or dispersed in the blend or mixture.

This invention further contemplates that the semiconductor-nanocrystals, rods, can be aligned by any techniques known in the art for aligning crystals.

By "photovoltaic device" it is meant to include those typical device architectures known in the art. Exemplary photovoltaic devices are described in, for example, *Science*, Vol. 295, pp. 2425-2427, March 29, 2002, the contents of which are incorporated by reference. An exemplary photovoltaic device may have nanocrystal particles in a binder. This combination can then be sandwiched between two electrodes (*e.g.*, an aluminum electrode and an indium tin oxide electrode) on a substrate to form a photovoltaic device.

By "binary solvent system" it is meant to include a system of two solvents, and one may be a ligand that is also a solvent. For example, pyridine in chloroform. "Binary solvent system" is also meant to include a system of at least one solvent, and a ligand that is not a solvent, for example xylene and phosphonic acid. Xylene is a solvent for the semiconductor nanocrystal and phosphonic acid is a ligand, but not a solvent.

Suitable methods for making thin films like those described herein are known. Non-limiting examples of various coating and printing techniques from solution include spin coating, blade coating, dip coating, inkjet printing and screen printing. All of these techniques are generally referred to herein as "depositing". That is, the thin films of the instant invention have to be "deposited" onto a substrate of some form.

The complementary electronic properties of inorganic and organic semiconductors can be used in the formation of electrically active junctions. Charge transfer is favored between high electron affinity inorganic semiconductors and relatively low ionization potential organic molecules and polymers. In one embodiment of the instant invention semiconductor nanoparticles, such as CdSe nanocrystals are combined with conjugated

polymers such as P3HT to create charge transfer junctions with high interfacial area resulting in photovoltaic devices having improved efficiency. From the energy level diagrams for CdSe nanocrystals and P3HT, it can be seen that CdSe is electron-accepting and P3HT is hole-accepting (FIG 1). The presence of ligands on the surface of nanocrystals mediates its interaction with the polymer. We can replace or remove ligands on the surface of CdSe through chemical washing of nanocrystals or heat treatment of CdSe-P3HT blend films after they have been cast.

The effectiveness of charge transfer and transport is determined by the morphology of the blend. Aggregation of nanocrystals both in solution and in the polymer depends on the strength of the van der Waals interaction between the particles and thus on the separation between nanocrystals and their size. A balance between aggregation for transport of electrons and dispersion for more efficient charge transfer is required. The inventors have surprisingly discovered that fine control of morphology is obtained through the use of solvent mixtures. Solvent mixtures according to embodiments of this invention that contain pyridine, which is a ligand and solubilizes nanocrystals, can influence the dispersion of the nanocrystals in solution. Since spin casting is a non-equilibrium process, the dispersion of the nanocrystal in solution can be maintained in the polymer.

According to one embodiment of the invention a solvent mixture is used to control the phase separation down to the nanometer scale. The inventors have surprisingly found that it is possible using a solvent mixture to control phase separation in a film with a high concentration of nanocrystals (up to 90-95 weight %) in polymer, in particular P3HT down to the nanometer scale. The aim is to enhance the solubility of the nanocrystals by simultaneously using a good solvent and ligand for nanocrystals, and in particular CdSe, and a good solvent for the polymer for solution processing. A preferred example is the weak-binding Lewis base, pyridine, with its relatively low boiling point of 116°C which was chosen as a ligand for the nanocrystals with the aim of facile removal. Pyridine treated nanocrystals of various shapes and sizes (FIG 3) were co-dissolved with P3HT in a mixture of 4% to 12% by volume (vol. %) pyridine in chloroform to create a uniform film consisting of dispersed particles in polymer when spin cast. The preferred amount of pyridine to cover the nanocrystal surface is determined by the number of non-passivated Cd surface sites on the nanoparticle. Pyridine is miscible in chloroform, so that there is a twofold solubility increase for the nanocrystals: (a) pyridine coated nanocrystals are more soluble in chloroform than their naked counterparts and (b) they are highly soluble in the excess pyridine that is not bound to nanocrystals. Too much pyridine, however, is to be avoided, as this mediates the

precipitation of P3HT, which is very soluble in chloroform and insoluble in pyridine.

Therefore, there are three solubility regimes:

- I. The low pyridine concentration regime: Insufficient solubility of the nanocrystals results in large-scale phase separation in the blend films promoted by nanocrystal
5 flocculation.
- II. The intermediate pyridine concentration regime: Provided that the polymer is still sufficiently soluble in a miscible blend of the two solvents, the solubility enhancement in the nanocrystal component of the blend solution will lead to intimate mixing of the two semiconductors and therefore prevent phase separation
10 upon spin coating.
- III. The high pyridine concentration regime: As pyridine is a non-solvent for the polymer component, we expect large-scale phase separation promoted by the flocculation of polymer chains.

To investigate the morphology of nanocrystal-polymer films sensitive techniques
15 such as atomic force microscopy (AFM), and bulk sensitive techniques such as transmission electron microscopy (TEM) are used. An example of regime I is shown in FIG 4 for a blend of 90 wt. % 7 nm by 7 nm nanocrystals in P3HT that was spun from a single solvent of chloroform. FIG 4 shows phase separation on a scale of several microns, which could also be detected under an optical microscope and even with the bare eye as the film scattered light.
20 Light scattering is undesirable in thin film photovoltaic cells, as it can decrease the fraction of light absorbed.

The study of the surfaces of nanocrystal-polymer blend films can be greatly enhanced by using AFM in the tapping mode (TM), as it is often possible to identify local differences in the composition of the film by comparing the phase and topography image.

25 To illustrate the transition from regime I to regime II, FIG 5 shows the AFM-TM topography and phase images for 5 μm scan areas of 9 nm by 13 nm nanorod-P3HT blend films spun from solvent mixtures with low and intermediate pyridine concentrations. Whereas the topography of these films is very rough for low pyridine concentration, an intermediate concentration yields much smoother films. The corresponding AFM-TM phase images
30 demonstrate that the surface roughness relates to phase separation. Phase separation between the nanocrystals and polymer do not yield single material domains and as such, it is not possible to identify the individual polymer and nanocrystal areas. At low pyridine concentration, there is clear evidence for local variations in the composition of the film,

whereas at intermediate pyridine concentration the phase image is very smooth. We can therefore attribute these two concentrations to regime I and II, respectively.

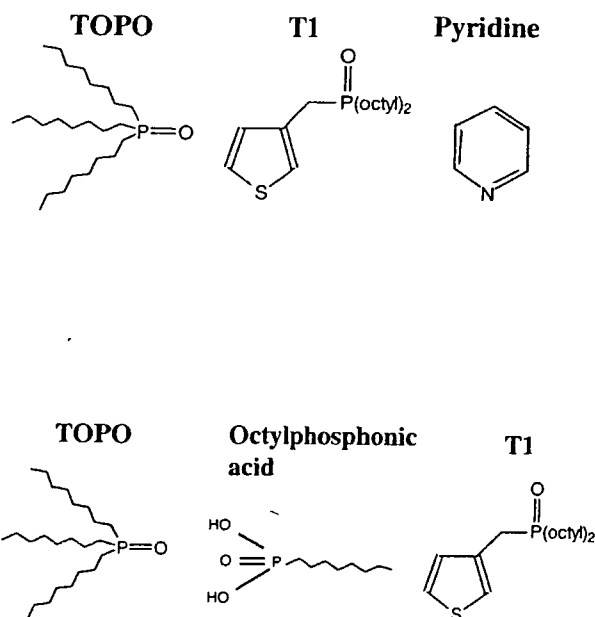
In yet another embodiment of this invention, it is contemplated that the high loading of semiconductor-nanocrystals in conjugated polymers in accordance with the instant invention results in a "smooth" thin film surface. This can be quantified. To express these results in a quantitative manner, the root mean square (RMS) of the film roughness is determined from AFM topography images as a function of pyridine concentration (FIG 6). The RMS roughness decreases by an order of magnitude, as the pyridine concentration increases from 0 to 5 vol. %. Between 5 and 12 vol. % pyridine concentrations, there is only a slight increase in the RMS roughness, whereas there is an order of magnitude increase, as the pyridine concentration is taken from 12 to 20 vol. %. Using the above scheme we can attribute the concentration range from 0 to 5 vol. % to regime I, 5 to 12 vol. % to regime II and 12 to 20 vol. % to regime III. These concentration values are for a fixed overall concentration of nanocrystals and polymer in the binary solution. For the 90 wt. % of CdSe nanocrystals in P3HT used here, the partial concentrations were 45g/l and 5g/l respectively. It is to be understood that concentrations expressed with regard to washing may vary as much as 20% and still be effective.

Separation of charges only occurs for excitons that are created within the exciton diffusion range of a nanocrystals-polymer interface. As the single-material domain size decreases as a consequence of better nanocrystal dispersion, an increase in the external quantum efficiency (EQE) is predicted. The EQE can be used as a measure of the efficiency of charge separation given that following quantities are comparable for a set of devices: (i) incident light intensity, (ii) fraction of light absorbed, and (iii) charge collection efficiency at the electrodes, which is mainly given by the choice of electrodes. These three conditions are met for the devices for which EQE data are presented in FIG 6. FIG 6 shows the pyridine dependence of the EQE for blends of P3HT and 9nm by 13nm CdSe nanocrystal. The EQE increases by a factor of 1.4 in going from regime I to regime II and then decreases again for regime III. In a preferred embodiment, the maximum EQE of 35% is found for a pyridine concentration of 8 vol.% in the solvent mixture, ie binary solvent system.

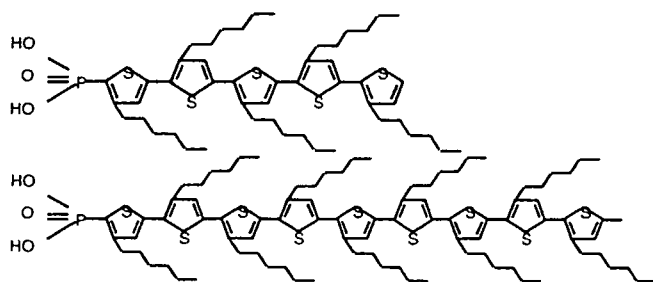
A similar dependence of the EQE on pyridine concentration in the binary solvent system exists for spherical nanocrystal dispersed in P3HT. The maximum EQE is also at 8 vol.% pyridine concentration, which is comparable to the value found for the low aspect ratio nanorods described above. For a fixed nanocrystal concentration, the optimal concentration of pyridine is determined by the surface-to-volume ratio of the nanocrystal. For devices

comprised of 3nm by 100nm nanorods, the best devices are cast from solutions containing 12 vol.% pyridine, whereas, devices with 7nm by 60nm nanorods require only 4 vol.% pyridine. The 3nm diameter nanorods have a factor of two higher surface-to-volume ratio than the 7nm nanorods. More pyridine is required to maintain the surface of the thinner nanorods covered
 5 with pyridine, as these bound pyridine molecules are in dynamic equilibrium with free pyridine in solution.

In another embodiment of the instant invention it is possible to vary the binary solvent mixture employed in accordance with this invention by substituting pyridine with another ligand. For example, CdSe, CdTe and InP nanocrystals are synthesized in a mixture of
 10 consisting of mostly TOPO or TOP and various phosphonic acids. After the nanocrystals are recovered and stored, there is a large excess of TOPO, (or TOP) in the product and the nanocrystals are passivated by this organic surfactant. Nanocrystals with a shell of TOPO are less prone to oxidation and dissolve readily in a large variety of solvents including toluene, chloroform, hexanes, THF, pyridine and butanol. TOPO can be replaced by other ligands for
 15 cadmium such as thiols, amines and other phosphine oxides and phosphonic acids, see below.



Non-conjugated ligands do not absorb in the visible portion of the electromagnetic spectrum and do not add to the photogenerated current of a solar cell. Oligothiophenes with phosphine oxide or phosphonic acid functionalities attached can bind to the surface of CdSe and other semiconductor-nanocrystals. These conjugated ligands with longer conjugation,
 5 above 4 monomer units, absorb in the visible region of the electromagnetic spectrum and can contribute to the photocurrent, and thus their use is contemplated by one embodiment of this invention. Phenylphosphonic acid is a non-limiting example of ligands of preferred use. The energy levels of oligothiophenes with greater than 10 monomer units approach that of the parent polymer, P3HT. TnPA is known as thiophene (n number of thiophene
 10 rings)phosphonic acid, shown below. There are three types of preferred thiophene derivative ligands contemplated for the instant invention. The number of thiophene rings can vary and they employ either phosphonic acid, phosphine oxide or an oligothiophene amine.



Because large oligomers bind closely to the nanocrystals and can interact intimately with the polymer, they can assist in improving the charge transfer rate between the two semiconductors. Oligomers that also have similar side chains to the polymer can help large nanocrystals repel each other and disperse well in the polymer. In a preferred case,
 20 nanocrystals are blended with a polymer that contains chemical functionalities such as phosphine and phosphine oxides to bind to the nanocrystal. In this instance, the polymer can be brought in close proximity to the nanocrystal to promote fast and efficient charge transfer.

To replace TOPO, or other synthetic solvent, the nanocrystals are washed with a suitable solvent for the particular surfactant in on the nanocrystal. Then the nanocrystals are
 25 dissolved in a solvent with an excess of the desired ligand to be used, and refluxed at high temperature for several hours. High temperature ensures movement of ligands on and off the nanocrystal surface and the excess maintains the equilibrium of the new ligand on the

nanocrystal surface. Another effective chemical treatment that reduces the exposure of nanocrystals to oxygen and water at high temperature is to dissolve the nanocrystals in an excess of the replacement ligand, then precipitate the particles in a solvent for TOPO, or other synthetic solvent and discard the supernatant after centrifugation. Pyridine, with a boiling point of 116°C, is one of the most facile ligands to displace, and is preferred for use with CdSe. Nanocrystals passivated by pyridine are less soluble than those covered by TOPO, but they can easily be stripped of pyridine by drying or heating the nanocrystals.

In photovoltaic devices fabricated with nanocrystal-polymer blends, the ligands on the nanocrystals determine the morphology of the film and the extent of microphase separation. The morphology of blends of CdSe with various ligands, including TOPO, pyridine and a modified TOPO in which one octyl moiety is replaced by a thiophene ring (T1), are compared in FIG 22.

As a non-limiting example, CdSe nanocrystals passivated by TOPO, with non-polar alkyl chains, can be dispersed uniformly in the non-polar matrix of P3HT. The distinct spacing between the particles corresponds to 11 Å, the approximate length of the TOPO molecule (FIG 22a). When TOPO is modified with the replacement of one octyl chain with a thiophene ring to give T1, these nanocrystals, when dispersed in P3HT, behave differently from TOPO coated particles (FIG 22b). Nanocrystals coated with T1 aggregate more than TOPO coated particles and the aggregates of CdSe nanocrystals assemble into lines of nanoparticles. While not wishing to be bound by any particular theory or principle, it is possible that the thiophene rings on the T1 molecules pi-stack with the thiophene rings on the polymer, causing the nanocrystals align along a polymer chain. The presence of surfactants on the nanocrystal surface can be discerned from the separation between particles within the aggregates and amongst the chains of nanocrystals. In contrast, nanocrystals coated by pyridine aggregate in P3HT (FIG 22c). While not wishing to be bound by any particular theory or principle, it is possible that because pyridine is a weak Lewis base, some of the pyridine is removed from the nanocrystal surface during the evaporation of the solvent as the films are cast. As a consequence, the van der Waals interaction between the largely polar nanocrystals in the non-polar P3HT results in microscale phase separation between the organic and inorganic components of the composite. Pyridine washed nanocrystals are in more intimate contact with neighbouring particles such that there is no distinct separation between nanocrystals in the film as was observed with TOPO coated particles. Similar differences in aggregation behaviour between TOPO and pyridine coated nanocrystals were observed for the polymer MEH-PPV, which is a more polar than P3HT.

It is understood that the instant invention contemplates as a preferred embodiment not actually replacing 95 % of the surfactant on the rods that is there from synthesis processing. Intuitively, one would think that washing 3 times would eliminate more residual surfactant, and this would be preferred, as the surfactant interferes with charge transfer. However, the
5 inventors have surprisingly found that with only one washing step, some surfactant is left on which results in a photovoltaic device having a much greater and unexpected results than one would have predicted. The EQE for such a device is improved 3 to 5 fold over those devices washed three times.

Nanocrystals 5nm in diameter are washed 3 times in methanol to remove excess
10 TOPO and then dissolved in a minimum of pyridine (50 μ l per 100mg CdSe) and precipitated in hexanes three times to obtain particles with pyridine on the surface. Methanol washed nanocrystals were refluxed first with pyridine to displace TOPO, precipitated with hexanes and then refluxed in a solution of T1 dissolved in toluene for 12 hours to yield T1 coated
15 nanocrystals in P3HT dissolved in chloroform on to NaCl IR windows. These samples were dipped in water to float off the blend films and copper TEM grids with holey carbon were used to pick up the films.

In another embodiment of the instant invention the inventors have surprisingly discovered that heat treatment is an effective method to enhance the mobility of organic
20 molecules bound to an inorganic surface and that treatment of the nanocomposite near the glass transition temperature of the polymer enables the movement of these molecules within the film towards the surface. In organic blends, thermal annealing has been used to promote the equilibrium morphology of a spin cast film and in some cases to enhance phase separation and crystallization within the composite. For nanocrystal-polymer blends, heat treatment
25 allows for modification of the nanocrystal-nanocrystal and nanocrystal-polymer interface to unexpectedly enhance charge transfer and transport in improving the performance of a photovoltaic device. The excess pyridine in the binary solvent, used to control the dispersion of nanocrystals in polymers, will be shown to act as non-radiative recombination centers for excitons created in P3HT. As a consequence, these excitons do not contribute to the
30 photocurrent. Thermal annealing of films in accordance with the embodiments of this invention results in removal of interfacial pyridine and excess, unbound pyridine within the polymer regions. Significant enhancements in EQE are observed in devices after heating,

which can be related to the recovery of these lost excitons for charge transfer and photocurrent generation.

The normalized photocurrent measured for a 90 wt.% 3nm by 60nm CdSe nanorods in P3HT spin cast from a solvent of 10 vol.% pyridine in chloroform is given in FIG 7a (open circles, prior to annealing; closed squares, after annealing). The absolute maximum EQE is 15% under $0.1\text{mW}/\text{cm}^2$ illumination at 455 nm under flowing argon. Upon heating at 120°C under reduced pressure of approximately 50mTorr for 3 hours and cooling for 8 hours to room temperature, the photocurrent of the same device is enhanced significantly (FIG 7a), higher than one would ordinarily expect.

While not wishing to be bound by any particular theory or principle, the unexpected results may be able to be explained as follows. A ratio of the photocurrent for the heated device to that of the device prior to heating shows an overall enhancement by a factor of 2.5 and a particularly strong increase by a factor of greater than 6 near 650nm with a shoulder at 700nm (FIG 7b). To understand the origin of this red EQE enhancement peak, a device with only 3nm by 60nm CdSe nanorods was fabricated and heated under the same conditions. An analysis of the photocurrent prior and subsequent to heat treatment shows that there is only an enhancement feature centered around 700nm. We can therefore attribute this red shift in the blend photocurrent to the nanorods. Consequently, without being bound to a particular theory or mechanism of operation, it is postulated that heat treatment is seen to aid both in the removal of interfacial pyridine and in bringing nanorods closer together resulting in unexpected and surprisingly superior efficiencies. This aggregation of neighboring nanorods is likely to improve electron transport between nanorods, for which the separation distance between hopping steps is decreased. Furthermore, the removal of interfacial pyridine can also have the effect of enhancing charge transfer between CdSe and P3HT by bringing these two materials into closer electronic contact. These two effects most likely resulted in the overall photocurrent enhancement by a factor of about 2.5 across all absorbed wavelengths.

The greatest photocurrent increase occurs in the region between 500nm and 700nm, where a factor of greater than 6 is obtained for the 90 wt.% CdSe blend device and both CdSe and P3HT contribute significantly to the absorption of light. To determine the relative contributions, we can compare the fraction of light absorbed with the fraction of the photocurrent produced by each material component. The absorption spectrum of a series of devices with varying CdSe concentration can be fitted into a linear combination of the individual CdSe and P3HT spectra (Fig 8).

There is no significant change in the absorption between 400nm and 700nm of the blend device after heating. For concentrations greater than 40 wt.%, the contribution of P3HT to the photocurrent is significantly less than the proportion of light that is absorbed by the polymer. In the 90 wt.% CdSe device, P3HT is responsible for 61% of the light absorbed but the polymer only contributes to 8% of the photocurrent. This indicates that a substantial amount of light absorbed by the P3HT does not contribute to the generation of current and is lost either to non-radiative or radiative recombination pathways. However, upon heat treatment of these devices at 120°C, the change in the photocurrent spectra yields P3HT contributions that are closer to the proportion of light that it absorbs. For the 90 wt.% CdSe device, the P3HT portion of the photocurrent increases dramatically to 66%, comparable to the 61% of the absorbed light in P3HT. This amplification of the external quantum efficiency is observed from 60°C to 160°C, decreasing once again at 180°C as aluminum migrates through the film and the device degrades, FIG 9. Correspondingly, the PL efficiency of a 60 wt.% CdSe blend film as a function of treatment temperature, rises up to 120°C, decreases thereafter and remains constant at higher temperature (FIG 9 inset). This invention contemplates that the thermal annealing temperature may be as great as 200°C.

These unexpected results may be explained as follows. Since the PL efficiency of CdSe in the blend is less than 0.1%, the PL of the sample arises predominantly from P3HT. Heating of P3HT is known to result in enhanced crystallinity, which quenches the PL efficiency. This effect is observed in heated films of P3HT at as low a temperature as 40°C. Increased crystallinity, therefore, explains the slight decrease in PL efficiency observed in the blend films above 120°C, but fails to account for the substantial increase in PL efficiency below 120°C. At low temperatures, the removal of excess pyridine within the polymer is the likely cause for the increase in P3HT PL efficiency with increasing treatment temperature. It is possible, that this is because some of the photons absorbed in P3HT undergo non-radiative recombination at pyridine sites within the polymer in the untreated film and do not contribute to PL. After heat treatment, these photons can contribute to both radiative decay and charge transfer. Consequently, the removal of excess pyridine results in a larger P3HT contribution to the photocurrent leading to the enhancement in EQE observed in the region between 500nm and 700nm.

Thermal treatment according to preferred embodiments of this invention is especially important to enhance EQEs in high aspect ratio nanorod devices, which have a high surface-to-volume ratio and require higher concentrations of pyridine (>8 vol.%) in the spin casting solution. In devices consisting of these nanorods, there are large nanorod-nanorod, and

nanorod-polymer interfacial areas containing pyridine as well as substantial amounts of excess pyridine. Removal of this pyridine resulted in the large EQE improvements of up to a factor of six observed in FIG 7. In contrast, nanorods of dimension 7nm by 60nm are blended with P3HT in solvents with only 4 vol.% pyridine and the maximum EQE increase after heating is by only a factor of 1.3 (FIG 10).

The instant invention contemplates the use of nanorods with low surface-to-volume ratios, and thus pyridine removal from thin films (<200 nm) results from merely pumping on the sample at low pressure (<10⁻⁶ mbar) and no improvement in performance is observed upon heat treatment. Moreover, heat treatment of thin films is detrimental to the open-circuit and fill factor as aluminum diffuses through a significant portion device.

In a series of 90 wt.% 7nm by 60nm nanorods CdSe in P3HT devices ranging from 100nm to 350nm in thickness, those above 200nm thickness improve upon heat treatment at 120°C (FIG 11).

As the device increases in thickness the relative enhancement of the EQE also rises (FIG 12a). The absolute improvement in EQE after treatment also increases with thickness (FIG 12b) but is limited at 346nm thickness due to the poorer transport properties of the thickest device. As hybrid nanorod-polymer solar cells become more efficient through nanorod alignment and the synthesis of rods greater than 100nm in length, thicker films with higher optical density to absorb more sunlight can be used. In these thick films, heat treatment is preferred to realize high performance devices.

In yet another embodiment of the instant invention the inventors have surprisingly realized unexpected strategies for increasing the carrier mobility and improving charge collection resulting in enhanced cell performance. For blends of an electron transport material with a hole transport material, the creation of percolation pathways is necessary to convey charges. In dispersion of nanocrystals with polymers, terminations in the pathways for electrons act as traps or recombination centres. Increasing the size of the nanocrystals reduces the number of these terminations and thus enhances the performance. However, to achieve the efficiencies observed in commercial solar cells, it is desirable to have higher carrier mobilities and lower recombination rates. With nanorods that have a length similar to the thickness of the device it is possible to have a directed pathway in which the carrier mobility is similar to that of a 1-dimensional wire. Thus the problems of percolation and hopping transport are eliminated. By controlling the aspect ratio of CdSe nanorods dispersed in P3HT, the inventors have surprisingly discovered that length scale and direction of electron transport can be tailored through a thin film PV device.

As nanocrystals increase in aspect ratio from spherical to rod-like, they move from the molecular regime closer to the realm of a one-dimensional wire and they become less readily soluble. In FIG 13a, nanorods aggregate in P3HT to form a single island spanning several microns when films are cast from chloroform. However, for the same concentration, the nanorods disperse uniformly within the polymer film when cast from a pyridine/chloroform solvent mixture, FIG 13b. This dispersion of nanorods in pyridine and chloroform is essential for the casting of uniform films as well as for creating a large charge transfer interface with P3HT for reduced exciton recombination.

Because the architecture of these solar cells is such that the electric field extends across the thickness of the device rather than in the plane, it is also important to characterize the morphology of the blend film in cross section. To accomplish this, a solution of 60 wt.% 10nm by 10nm CdSe nanocrystals in P3HT was spin cast from solution onto a Polybed epoxy disk. The disk was then microtomed with a diamond knife to yield 60nm thick films. These ultrathin films on one edge contain a cross section of the nanocrystal-P3HT blend. In the TEM image of the film FIG 14 the dark section without nanocrystals is the epoxy substrate, on which the P3HT film, approximately 100nm across, containing nanocrystals can be seen. The nanocrystals span the entire film thickness uniformly with no significant phase separation in the lateral direction.

Obtaining a cross section for long nanorod-polymer films was very difficult. The nanorods, because of their large size, resisted being cut and the blend films had a tendency to tear and be dragged by the knife. Consequently, the films, once they were spun onto an epoxy disk, were imbedded in epoxy resin over the span of two days and cured to provide further support during the microtoming. The resulting cross section for 40 wt. % 7nm by 60nm CdSe nanorods in P3HT shows nanorods spanning a substantial portion of the thickness of the film FIG 15b.

As the nanorods increase in length to span the thickness of a photovoltaic device, it is predicted that the electron transport will improve substantially. However, the predicted improvement in transport assumes that the nanorods are aligned perpendicular to the plane of the substrate and that they are long enough for the electrons to be transported entirely within one nanorod. FIG 15 reveals that the nanorods are randomly dispersed, but nevertheless, there are some particles oriented with a significant component along the direction of electron transport. Further evidence for the partial alignment of nanorods and the beneficial effects on electron transport can be observed in the photocurrent.

The EQE can be used as a measure of the efficiency of charge transport given that the following quantities are comparable for a set of devices: (i) incident light intensity, (ii) fraction of light absorbed, (iii) charge collection efficiency at the electrodes, which is mainly given by the choice of electrodes, and (iv) the charge transfer efficiency, as determined from photoluminescence quenching. These four conditions are met for the devices for which EQE data are presented in FIG 16. We can therefore conclude that as the aspect ratio of the nanorods increases from 1 to 10, FIG 17, the charge transport has to improve significantly to yield an EQE enhancement by a factor of approximately 3. In networks consisting of shorter nanoparticles, electron transport is dominated by hopping between discrete particles that comprise the pathway to the electron-collecting electrode. However in devices consisting of longer particles, band conduction is prevalent as pathways can be formed from a single nanorod. Because the thickness of the nanorod-polymer film in a device is approximately 200nm, a 60nm long nanorod can penetrate through a significant portion of the device while a 30nm and a 7nm long particle are progressively less effective, FIG 16. The best device, which contained 7nm by 60nm nanorods, performed with a maximum EQE of 55% under 0.1mW/cm² illumination at 485nm, and this value has been remarkably reproducible. The results reported represent the median of five sets of devices made on separate occasions from three different synthetic batches of CdSe totaling 57 individual solar cells. The maximum external quantum efficiency of each of these 57 devices are all within 10% relative to the median with the highest obtained efficiency at 59%, all under ~0.1mW/cm² monochromatic illumination. Individual devices have been characterized repeatedly over the time scale of several months and showed no significant change between measurements.

On account of the superior carrier transport properties of inorganic semiconductor nanorods as compared with semiconducting organic polymers and small molecules, these hybrid nanorod-polymer solar cells perform with the highest EQE, under low intensity illumination, reported for a polymer containing cell to date.

It is contemplated that the photovoltaic devices according to the instant invention incorporate highly branched nanorods. Highly branched nanorods were synthesized according to those techniques known in the prior art from 10 injections of precursors. Upon subsequent injections during the synthesis, these nanorods developed many nucleation sites for branching in addition to increasing in length. Because many of these branched nanorods have lengths above 100nm, further increases in EQE were expected when used in nanorod-polymer PV devices. Branching is caused by a low energy zinc blende defects in the wurtzite structure of the rods similar to stacking fault defects that cause the nanorods to have kinks

along its length. As a consequence, it is expected that the mobility of the carriers within the branched nanorods is similar to the unbranched rods. Furthermore, the interaction between a branch and the main body of the nanorod is stronger than between two discrete nanorods in physical contact. Thus, band transport is prevalent within a branched nanorod and hopping of
5 electrons occurs between discrete nanorods.

It is understood that embodiments of the invention include even more complex shaped nanocrystal particles. In embodiments of the invention, the initial nucleation event yields a core with a cubic crystal structure (*e.g.*, a zinc blende crystal structure). Later, arms with a hexagonal crystal structure (*e.g.*, wurtzite) can grow out from the core. However, different
10 growth conditions can be provided to statistically alternate the formation of cubic and hexagonal crystal structures, thus leading to irregular branching. Precise control of temperatures throughout the reaction may yield sequentially branched "inorganic dendrimers", see Mana et al., *J. Am. Chem. Soc.*, **2000**, 122, 12700-2706 and U.S. Serial No. 10/301,510, filed November 20, 2002, currently pending.

15 The inherent property of a tetrapod to self-align on a substrate with one arm always pointing towards one electrode, combined with the low band gap material such as CdTe, makes the tetrapod semiconductor-nanocrystal embedded in a conjugated polymer an especially preferred embodiment. In comparison to nanocrystal particles that are randomly oriented, the tetrapods according to embodiments of the invention are aligned and can
20 provide for a more unidirectional current path than randomly oriented nanocrystal particles.

The photocurrent spectra for a blend of 90 wt.% CdSe branched nanorods in P3HT for various pyridine concentrations are displayed in FIG 18. The preferred pyridine concentration for branched nanorods occurs at 12%, which is significantly higher than for shorter unbranched rods, which is 8% or less. The maximum EQE for these devices is 31%
25 under approximately 0.1 mW/cm² illumination at 450nm. Contrary to the predicted results, this EQE is almost a factor of two lower than the devices from 60nm nanorods.

The dispersion of longer nanorods (>100nm) in P3HT is limited by their solubility in pyridine-chloroform. The branched nanorods, when dissolved in pyridine-chloroform, formed a gelatinous, viscous solution. This is an indication of the lower solubility of the branched
30 objects and the higher nanorod-nanorod interaction relative to the nanorod-solvent interaction. With these branched objects, the CdSe-P3HT films cast were non-uniform and scattered light, a clear indication of macrophase separation. Any enhancement in transport efficiency is compromised by the decrease in charge separation efficiency resulting from a decrease in interfacial area between nanorods and P3HT.

Long cadmium selenide nanorods, in solution at high concentrations and passivated by pyridine, are separated by small distances, in some cases the diameter of pyridine. Under such proximity, the van der Waals attraction, which scales as the volume and distance is very strong and promotes agglomeration. To solubilize long nanorods at the high concentrations required for making sufficiently thick films for PV devices is a challenge. Ligands with greater size and longer chains are required to extend the length of nanorods added to polymers. To prevent these ligands from acting as a barrier layer they must be electrically active and the energy levels must be such that charge transfer between CdSe and P3HT is facile.

Full band conduction of electrons requires that the transport be contained entirely within a single nanocrystal. Further improvements in transport rely on the alignment of nanorods across the film thickness. Methods for nanorod alignment include electric field and stretch alignment, both of which require significant modifications of the current device processing and architecture. Tetrapods, with four identical nanorod arms attached at a cubic center, orient themselves naturally on a surface with one arm perpendicular to the substrate plane as seen in FIG 19. The next generation of hybrid solar cells could therefore incorporate tetrapods as self-aligning nanocrystals to transport electrons efficiently.

Another embodiment of the instant invention is the surprising film thickness that the nanorod/polymer photovoltaic devices of the instant invention operate at. One of the many advantages of using nanocrystals and polymers are the high absorption coefficients compared to bulk inorganic semiconductors. These form thin films, typically less than 300nm, which are able to absorb more than 90% of the incident radiation. Unlike conventional inorganic semiconductor solar cells, which require more than several micron thicknesses to absorb light, low material usage and flexible devices are possible with nanocrystals and polymers. While not wishing to be bound by any particular theory or mechanism it is possible that because the good transport properties of nanorods can be utilized when the length of the nanorods spans a significant portion of the film, the dependence of the efficiency of nanorod-polymer PV devices with film thickness provides further information about the nature of carrier transport.

The photocurrent spectra of the devices for which the absorption is discussed above are shown in FIG 20. As the film thickness increases from 100nm to 350nm, the corresponding increase and subsequent decrease in EQE does not arise solely from increase in absorbed light. The shape of the spectra depends on the thickness of the device and the

photoresponse in the red regions of the spectra increases with thicker films. This can be attributed to a weak filter effect that results from part of the film not contributing to the photocurrent. Because in thick films networks of physically touching nanorods transport electrons with low carrier mobility, compared to transport contained entirely in one particle, and electrons generated near the PEDOT:PSS electrode must traverse many nanorods to reach the collecting aluminum electrode. Blue light, which is absorbed closer to the transparent electrode, does not strongly contribute to the photocurrent. In addition, the electric field across the device responsible for charge separation is decreased at a given voltage bias for a thicker film as compared with the thinner one.

The instant inventors have surprisingly discovered that nanorod-polymer devices can be made significantly thicker at 200nm to achieve more absorption of light because the dispersion characteristics of the nanorods are well controlled and the transport properties in the nanorods are more efficient than the mentioned organic materials.

The photocurrent spectra of 90 wt. % 7nm spherical nanocrystals in P3HT devices display similar properties, FIG 21a. The absorption spectra of the set of devices with varying thicknesses are shown in FIG 21b. As the thickness of the device increases, the EQE as a function of wavelength shows a more pronounced response in the red regions of the spectrum. For these spherical nanocrystals, the optimum device thickness is at 160 nm, which can be compared with the optimum of 212 for long nanorod devices. Because long nanorods show improved electron transport relative to shorter dimension spheres, devices can be made thicker to absorb more light, before hopping transport begins to dominate. This further provides evidence for the benefits of using one-dimensional nanorods to improve transport.

In another embodiment of the invention there is disclosed herein a photovoltaic device incorporating a PEDOT:PSS (poly(ethylene-dioxy)thiophene:poly(styrene sulphonic acid)) hole transporting layer on top of an ITO electrode. The incorporation of a hole conducting layer on top of the ITO electrode (PEDOT/PSS) gives a number of beneficial effects including, e.g., providing a much smoother surface upon which to deposit, e.g., by spin casting, the nanocomposite layer, and, its work function matches the valence band of the conducting polymer (P3HT) much better than does ITO, thereby facilitating hole conduction. Of course, one may select a variety of different hole conducting layers depending upon the work function of the electrode material that is employed. A non-limiting example of this device is shown in FIG 4. The most preferred embodiment of the instant invention is a semiconductor nanocrystal-polymer solar cell constructed by spin-casting a solution of 90 wt.% 7nm by 60nm CdSe nanorods in P3HT onto an ITO glass substrate coated with

PEDOT:PSS with aluminum as the top contact. A power conversion efficiency of 6.9% was obtained under 0.1mW/cm^2 illumination at 515nm inside an inert atmosphere of flowing argon. At this intensity, the open circuit voltage is 0.5V, the photovoltage at the maximum power point is 0.4V and the fill factor is 0.6, FIG 23a. For plastic PV devices, this monochromatic power conversion efficiency is one of the highest reported. Very few polymer-based solar cells are able to attain monochromatic power conversion efficiencies above 2%. The most reliable example is that of a blend from a soluble derivative of C₆₀ and MEH-PPV, which reaches an efficiency of 5%.

In another embodiment of the invention, alignment of the semiconductor-nanocrystals across the film thickness can be further controlled with external aids. Alignment aids can include aids that are known to those of ordinary skill in the art. These include aids that can produce an electrical, magnetic fields or stretch alignment, that can be used to align the nanocrystals. For the purposes of this invention alignment may be defined if between 10 and 99% of the nanocrystals have their longitudinal axis aligned not more than 20 degrees from the normal to the thin film plane.

Experimental.

The above description has numerous embodiments of the instant invention detailed therein. Some parameters of the above embodiments are summarized in Table 1. Further non-limiting examples of the instant invention are detailed below. Pyr/Chlor. is a pyridine in chloroform mixture

Table 1

nanocrystal loading, wt %	nanocrystal size, nm	nanocrystal material/polymer	solvent mixture	solvent amount, vol %	Reference
90	7 x 7	CdSe/P3HT	pyr/chlor.	100	FIG 4
90	9 x 13	CdSe/P3HT	pyr/chlor	0-20	FIG 6
90	3 x 100	CdSe/P3HT	pyr/chlor	12	
90	7 x 60	CdSe/P3HT	pyr/chlor	4	
0-95	3 x 60	CdSe/P3HT	pyr/chlor		FIG 8
60	10 x 10	CdSe/P3HT	pyr/chlor		FIG 14
40	7 x 60	CdSe/P3HT	pyr/chlor		FIG 15

Nanocrystals were synthesized using pyrolysis of organometallic precursors in a mixture consisting mainly of trioctylphosphine oxide (TOPO) and tributyl- or trioctylphosphine and small amounts of various phosphonic acids by those techniques known in the art, see Peng et al., *Nature* 2000, **404**, 59; and Peng et al. *J. Am. Chem. Soc.* **2001**, *123*, 1389. The recovered product was dispersed and washed three times in methanol to remove excess surfactant. Pyridine treatment of the nanocrystals to remove the surfactant used in the synthesis of nanorods was accomplished by dissolving the particles in pyridine and subsequent precipitation in hexanes. Whereas TOPO coated CdSe nanocrystals are soluble in hexanes, pyridine-coated particles are insoluble in hexanes. Repeating the pyridine treatment two to three times can effectively replace more than 95 % of the TOPO on the nanocrystal surface with pyridine.

CdTe tetrapods were synthesized as described in U.S. Serial No. 10/301,510, filed November 20, 2002, currently pending, substantially as follows. Cadmium oxide (CdO) (99.99+ %), Tellurium (Te) (99.8 %, 200 mesh), and tri-*n*-octylphosphine oxide (C₂₄H₅₁OP or TOPO, 99 %) were purchased from Aldrich. *n*-Octadecylphosphonic acid (C₁₈H₃₉O₃P or ODPA, 99 %) was purchased from Oryza Laboratories, Inc. Trioctylphosphine (TOP) (90 %) was purchased from Fluka. All solvents used were anhydrous, purchased from Aldrich, and used without any further purification. All manipulations were performed using standard air-free techniques. The Cd/Te molar ratio was varied from 1:1 to 5:1, and the Cd/ODPA molar ratio was varied from 1:2 to 1:5. The Te precursor solution was prepared by dissolving tellurium powder in TOP (concentration of Te 10 wt.%). The mixture was stirred for 30 minutes at 250 °C then cooled and centrifuged to remove any remaining insoluble particles. In a typical synthesis of CdTe tetrapods, a mixture of ODPA, TOPO, and CdO was degassed at 120 °C for 20 minutes in a 50 ml three-neck flask connected to a Liebig condenser. It was heated slowly under Ar until the CdO decomposed and the solution turned clear and colorless. Next, 1.5 g of trioctyl phosphine (TOP) was added and the temperature was further raised to 320 °C. After that, the Te:TOP precursor solution was injected quickly. The temperature dropped to 315 °C and was maintained at this value throughout the synthesis. All syntheses were stopped after 5 minutes by removing the heating mantle and by rapidly cooling the flask. After cooling the solution to 70 °C, 3 - 4 ml anhydrous toluene were added to the flask, and the dispersion was transferred to an Ar drybox. The minimum amount of anhydrous methanol, which was used to precipitate the nanocrystal particles after centrifugation, was added to the dispersion. In this way, potential co-precipitation of the Cd-phosphonate complex was prevented. After removing the supernatant, the precipitate was re-

dissolved twice in toluene and re-precipitated with methanol. After removing the supernatant, the final precipitate was stored in the drybox. All resulting CdTe tetrapods were readily soluble in solvents such as chloroform or toluene.

Example 1. According to one embodiment of the invention, photovoltaic devices were fabricated from spin casting a solution of CdSe nanocrystals and P3HT in a pyridine-chloroform solvent mixture onto an ITO coated glass substrate under inert atmosphere, pumping for 12 hours under $<10^{-6}$ mbar and evaporating aluminum on top to obtain the structure depicted in FIG 2.

Example 2. a. Nanocrystal Synthesis: According to another embodiment of the invention long CdSe nanorods in P3HT (90 wt% CdSe) were synthesized as follows: Cd stock: 0.161 g of dimethylcadmium was dissolved in 0.34 g of trioctylphosphine (TOP). Se stock: 0.2 g of Se in 2.367 g of TOP was dissolved. In a three neck flask, 3.536 g of trioctylphosphine oxide (TOPO), 0.187 g of hexylphosphonic acid (HPA), and 0.357 g tetradecylphosphonic acid (TDPA) were mixed. This mixture was heated and degassed under argon to 360C. Cd stock was slowly injected, then the temperature was lowered to 330C the Se stock was rapidly injected. The reaction was allowed to proceed at 290C for 18 minutes then the heat was removed. At 40C, about 15 mL of methanol was added to the flask. The mixture was centrifuged and the supernatant was discarded. 8 mL of methanol was added, vortex, then again centrifuge, discarding the supernatant.

b. Substrate Preparation: Wash indium tin oxide (ITO) on glass substrates by sonication in a series of solvents. After the final solvent wash, dry the samples and insert them into a precleaned plasma chamber. Treat the samples face down with a plasma for 4 minutes. As soon as the samples are removed from the chamber, begin deposition of PEDOT:PSS (purchased from Bayer – electronic grade). Deposit PEDOT:PSS by spin casting at 3000 rpms after filtering through a 0.2 micron acetate filter. Dry the films by heating under flowing argon for one hour at 120C.

c. Nanocrystal washing: Divided the synthesized nanorods in half and added 8 mL of methanol to each half. Centrifuged and discarded the supernatant, then repeated this process again. Added 0.35 mL of pyridine to each half to dissolve the nanorods, heated at 120C and occasionally vortexed for 10 min. Precipitated with 8 mL of hexane for each half. Centrifuged and discarded the supernatant. Dissolved the nanorods in a chloroform/pyridine mixture with 9.2% pyridine to give a concentration of 83 mg/mL of nanocrystals.

d. Active Layer Deposition Dissolved regioregular poly(3-hexylthiophene) (P3HT) in chloroform at 30 mg/mL. Used this solution and the above described nanorod solution

(see III above) to prepare a cosolution of nanorods and P3HT in a chloroform/pyridine mixture with a 9:1 mass ratio of nanorods to P3HT and a P3HT concentration of 4.55 mg/mL. From this solution, spin cast a thin film on a prepared substrate (see II above) at 1350 rpm.

- e. Electrode Deposition : Loaded the samples into an evaporation chamber and
5 allowed them to pump under vacuum for at least 8 hours, reaching a pressure below 10^{-6} torr. Thermally deposited an aluminum film approximately 100 nm thick through a shadow mask to define the top electrodes.

Example 3: CdTe tetrapods in P3HT

- CdTe tetrapod nanocrystals having a core and 4 arms of approximately 80nm in length were
10 synthesized then washed with several dissolution/precipitation steps in tetrahydrofuran (THF) and ethylacetate.

The nanocrystals were then codissolved in solvent chloroform with the ligand phenylphosphonic acid and heated at around 100C for several hours.

The nanocrystals were then precipitated with methanol and redissolved in chloroform.

- 15 The nanocrystal solution was mixed with a P3HT solution as described in example 2 and spin cast to create thin films.

Substrates and electrodes were processed as in example 2. The EQE value for this sample was less than 10%.

Example 4: CdTe tetrapods in P3HT

- 20 CdTe tetrapods were synthesized and washed with toluene and methanol as in example 3 (with THF and ethylacetate).

The nanocrystals (about 50 mg) were then codissolved in about 2 ml solvent chloroform with about 1000 mg of ligand hexylphosphonic acid (HPA) and heated for several hours.

- The rest of the procedure followed example 3. The EQE value for this sample was less than
25 10%.

Example 5: CdTe tetrapods in P3HT

Proceeded as in example 4, but additionally dissolved the nanocrystals in tributylphosphine (TBP) and stirred for 20 hours before precipitating with methanol.

Then proceeded as in example 3. The EQE value for this sample was less than 10%.

- 30 Example 6: CdTe tetrapods in MEH-PPV

Proceed as in example 3, but redissolve nanocrystals in solvent p-xylene after final methanol precipitation. This example thus will have the ligand phenylphosphonic acid.

Prepare a solution of MEH-PPV in p-xylene, mix this with the nanocrystals and this can be cast blend into films as in example 2.

Example 7: CdSe nanorods in P3HT

Proceed as in example 2 except the ligand pyridine can be replaced with n-butylamine or n-hexylamine in every step.

Example 8: CdSe nanorods in P3HT

- 5 Proceed as in example 4, but replace CdTe nanocrystals with CdSe nanocrystals.

Also, replace HPA with T1 for use as the ligands.

Example 9: CdSe or CdTe nanocrystals in P3HT

Proceed as in example 8 with either CdSe or CdTe nanocrystals.

Replace HPA with T5-PA

10 Characterization of Samples.

Nanocrystal size, morphology and structure were measured by TEM using a FEI Tecnai 12 120kV microscope. Thin films of CdSe-P3HT (regioregular P3HT from Aldrich) blends approximately 50-100 nm thick were investigated using TEM by casting a film on a NaCl IR window, floating the film in water and picking it up with a copper TEM grid. The morphology of the blend films was also characterized directly on devices via atomic force microscopy in tapping mode using a Nanoscope IIIa from Digital Instruments. Film thicknesses were determined via AFM.

- 15 The absorption of the CdSe-P3HT blend films was determined with an Agilent Chemstation UV/Vis spectrophotometer. Photocurrent measurements were completed using a 250 Watt tungsten light source coupled to an Acton SP150 monochromator as an illumination source and a Keithley 236 Source Measure Unit to obtain current and voltage. The light intensity was measured with a calibrated Graseby silicon photodiode.

- Photoluminescence quenching experiments were completed on CdSe-P3HT films of thickness 100-200 nm spin cast on glass substrates. The absolute photoluminescence of the sample under excitation at 514 nm from an argon ion laser was measured with an integrating sphere following the method described by deMello *et al*, *Adv. Mater.* **1997**, 9, 230.

- The efficiency of a photovoltaic device can be described in two ways, see Rostalski, J. *Sol. Energy Mater. Sol. Cells* **61**, 87 (2000), the contents of which are hereby incorporated by reference in its entirety. The first is a number efficiency, the external quantum efficiency (EQE), which expresses the number of photons that are converted to electrons. The second is a power conversion efficiency, which states how much electrical power is produced per unit of incident radiative power. Although the EQE is important to understand the mechanisms of current generation, it is rarely given as measure of the efficiency of a commercial solar cell.

More important for these commercial devices is the power conversion efficiency of the device under solar conditions.

For commercial applications, the most important parameter is the power conversion efficiency η of a photovoltaic cell. Since electrical power is a product of the current and voltage, the power conversion efficiency is determined from measuring the current as a function of voltage. The power conversion efficiency can be expressed in terms of the power of the incoming light P_{light} and the electrical output power P_{out} of the cell:

$$\eta(\lambda) = \frac{P_{out}(\lambda)}{P_{light}(\lambda)}$$

The maximum theoretical power output is given by the product of the short circuit photocurrent I_{sc} and the open circuit voltage V_{oc} . FIG 24 shows both the ideal and a typical I-V curve found experimentally. The area of the inner rectangle corresponds to the maximal output power of the real device (at the maximum power point), whereas the area of the outer rectangle formed by the axes and the ideal I-V curve is equivalent to the maximum ideal output power. Real I-V characteristics are curved and we have to maximize the product of current and voltage in order to obtain the maximum power output. The ratio between the maximum theoretical power output and the actual maximum power output is an important feature of the I-V characteristics. This ratio is called the fill factor FF and can be defined as

$$FF(\lambda) = \frac{\max_{0 < V < V_{oc}} \{I(V(\lambda)) \cdot V(\lambda)\}}{I_{sc}(\lambda) \cdot V_{oc}(\lambda)}$$

If we express the maximum output power of a photovoltaic cell using the fill factor, the power conversion efficiency becomes

$$\eta(\lambda) = \frac{I_{sc}(\lambda) \cdot V_{oc}(\lambda) \cdot FF(\lambda)}{P_{light}(\lambda)}$$

A large amount of information is contained within the I-V characteristics of a device. The I_{sc} is proportional to the EQE and coupled with the V_{oc} and FF , it provides all the parameters required to characterize the power efficiency of the cell.

The invention described herein contemplates that photovoltaic cells described herein have a power conversion efficiency of at least greater than 1% A.M. 1.5 global illumination. More preferably the amount is greater than 5 %. Even more preferably the amount is greater than 10 %. Most preferably the amount is up to 30 %.

The power conversion efficiency can be given under monochromatic or white light illumination. Monochromatic power conversion efficiencies are not sufficient to characterize

a solar cell but are a measure of the performance of the device at a specific wavelength. This is useful for the case that the device is intended for use under conditions other than solar, such as in small electronic devices and watches which function under ambient room lighting or as a power meter for laser radiation. The standard method of characterizing a solar cell is
5 under Air Mass 1.5 or A.M 1.5 conditions (sun's emission spectrum after traveling 1.5 times through the Earth's atmosphere). This solar illumination is generally simulated, as standard A.M 1.5 conditions are difficult to obtain reliably due to non-ideal weather conditions.

The terms and expressions which have been employed herein are used as terms of description and not of limitation, and there is no intention in the use of such terms and
10 expressions of excluding equivalents of the features shown and described, or portions thereof, it being recognized that various modifications are possible within the scope of the invention claimed. Moreover, any one or more features of any embodiment of the invention may be combined with any one or more other features of any other embodiment of the invention, without departing from the scope of the invention.

15 All patents, patent applications, and publications mentioned above are herein incorporated by reference in their entirety for all purposes. None of the patents, patent applications, and publications mentioned above are admitted to be prior art.

WHAT IS CLAIMED IS:

1. A thin film, comprising:
a semiconducting conjugated polymer having at least 5 wt% semiconductor-nanocrystals embedded therein, wherein:
at least a portion of the semiconductor-nanocrystals have an aspect ratio greater than
5 about 2.
2. The thin film of claim 1, wherein:
at least a portion of the semiconductor-nanocrystals have an aspect ratio greater than
about 5.
3. The thin film of claim 1, wherein:
10 at least a portion of the semiconductor-nanocrystals have an aspect ratio greater than
about 10.
4. The thin film of claim 1, wherein:
at least a portion of the semiconductor-nanocrystals have an aspect ratio of between
about 5 and about 50.
- 15 5. The thin film of claim 1, wherein:
at least a portion of the semiconductor-nanocrystals have an aspect ratio of between
about 2 and about 10.
6. The thin film of claim 1, wherein:
the semiconducting conjugated polymer has between about 5 and about 99 wt% of
20 semiconductor-nanocrystals embedded therein.
7. The thin film of claim 1, wherein:
the semiconducting conjugated polymer has between about 20 and 95 wt%
semiconductor-nanocrystals embedded therein.
8. The thin film of claim 1, wherein:
25 the semiconducting conjugated polymer has between about 50 and 95 wt%
semiconductor-nanocrystals embedded therein.
9. The thin film of claim 1, wherein:
the semiconducting conjugated polymer has about 90 wt% semiconductor-nanocrystals embedded therein.
- 30 10. The thin film of claim 1, wherein:
the semiconducting conjugated polymer is chosen from the group consisting of trans-polyacetylenes, polypyrroles, polythiophenes, polyanilines, poly(p-phenylene)s and

poly(p-phenylene-vinylene)s, polyfluorenes, polyaromatic amines, poly(thienylene-vinylene)s and soluble derivatives thereof.

11. The thin film of claim 10, wherein:

5 the conjugated polymer is chosen from the group consisting of (poly(2-methoxy 5-(2'-ethylhexyloxy)p-phenylenevinylene) (MEH-PPV) and poly(3-hexylthiophene, (P3HT).

12. The thin film of claim 1, wherein:

the semiconductor-nanocrystals comprise rods having a length of greater than about 20 nm.

10 13. The thin film of claim 1, wherein:

the semiconductor-nanocrystals comprise rods having a length of between about 20 nm and about 200 nm.

14. The thin film of claim 13, wherein:

15 the semiconductor-nanocrystals comprise rods having a length of between about 60 nm and about 110 nm.

15. The thin film of claim 1, wherein:

the semiconductor-nanocrystals comprise rods that are about 7 nm x 60 nm.

16. The thin film of claim 1, wherein:

20 the semiconductor-nanocrystals comprise a semiconductor selected from the group consisting of Group II-VI, Group III-V, Group IV semiconductors and tertiary chalcopyrites.

17. The thin film of claim 16, wherein:

the semiconductor-nanocrystals are selected from the group consisting of CdSe, CdTe, InP, GaAs, CuInS₂, CuInSe₂, AlGaAs, InGaAs, Ge and Si.

25 18. The thin film of claim 1, wherein

the semiconductor-nanocrystals are selected from the group consisting of CdSe and CdTe.

19. The thin film of claim 1, wherein:

a portion of the semiconductor-nanocrystals are branched nanocrystals.

30 20. The thin film of claim 19, wherein:

a portion of the branched nanocrystals have at least two arms, said arms are not all the same length.

21. The thin film of claim 19, wherein:

the branched nanocrystals do not all have the same shape.

22. The thin film of claim 19, wherein:
the branched nanocrystals have 4 arms and have a tetrahedral symmetry.
23. The thin film of claim 22, wherein:
the branched nanocrystals are either CdSe or CdTe and are embedded in an amount of
5 about 90 wt%.
24. The thin film of claim 1, wherein:
the film has a thickness of from about 100 nm to about 350 nm.
25. The thin film of claim 22, wherein:
the film has a thickness of about 200 nm.
- 10 26. A photovoltaic device, comprising:
the thin film of claim 1.
27. The photovoltaic device of claim 26, wherein:
at least a portion of the semiconductor-nanocrystals have an aspect ratio greater than
about 5.
- 15 28. The photovoltaic device of claim 26, wherein:
at least a portion of the semiconductor-nanocrystals have an aspect ratio greater than
about 10.
29. The photovoltaic device of claim 26, wherein:
at least a portion of the semiconductor-nanocrystals have an aspect ratio of between
20 about 5 and about 50.
30. The photovoltaic device of claim 26, wherein:
at least a portion of the semiconductor-nanocrystals have an aspect ratio of between
about 2 and about 10.
31. The photovoltaic device of claim 26, wherein:
25 the semiconducting conjugated polymer has between about 5 and about 99 wt% of
semiconductor-nanocrystals embedded therein.
32. The photovoltaic device of claim 26, wherein:
the semiconducting conjugated polymer has between about 20 and 95 wt%
semiconductor-nanocrystals embedded therein.
- 30 33. The photovoltaic device of claim 26, wherein:
the semiconducting conjugated polymer has between about 50 and 95 wt%
semiconductor-nanocrystals embedded therein.
34. The photovoltaic device of claim 26, wherein:

the semiconducting conjugated polymer has about 90 wt% semiconductor-nanocrystals embedded therein.

35. The photovoltaic device of claim 26, wherein:

5 the semiconducting conjugated polymer is chosen from the group consisting of trans-polyacetylenes, polypyrroles, polythiophenes, polyanilines, poly(p-phenylene)s and poly(p-phenylene-vinylene)s, polyfluorenes, polyaromatic amines, poly(thienylene-vinylene)s and soluble derivatives thereof.

36. The photovoltaic device of claim 35, wherein:

10 the conjugated polymer is chosen from the group consisting of (poly(2-methoxy5-(2'-ethylhexyloxy)p-phenylenevinylene) (MEH-PPV) and poly(3-hexylthiophene, (P3HT).

37. The photovoltaic device of claim 26, wherein:

the semiconductor-nanocrystals comprise rods having a length of greater than about 20 nm.

15 38. The photovoltaic device of claim 26, wherein:

the semiconductor-nanocrystals comprise rods having a length of between about 20 nm and about 200 nm.

39. The photovoltaic device of claim 38, wherein:

20 the semiconductor-nanocrystals comprise rods having a length of between about 60 nm and about 110 nm.

40. The photovoltaic device of claim 26, wherein:

the semiconductor-nanocrystals comprise rods that are about 7 nm x 60 nm.

41. The photovoltaic device of claim 26, wherein:

25 the semiconductor-nanocrystals comprise a semiconductor selected from the group consisting of Group II-VI, Group III-V, Group IV semiconductors and tertiary chalcopyrites.

42. The photovoltaic device of claim 41, wherein:

the semiconductor-nanocrystals are selected from the group consisting of CdSe, CdTe, InP, GaAs, CuInS₂, CuInSe₂, AlGaAs, InGaAs, Ge and Si.

30 43. The photovoltaic device of claim 26, wherein:

the semiconductor-nanocrystals are selected from the group consisting of CdSe and CdTe.

44. The photovoltaic device of claim 26, wherein:

a portion of the semiconductor-nanocrystals are branched nanocrystals.

45. The photovoltaic device of claim 44, wherein:
a portion of the branched nanocrystals have at least two arms,
said arms are not all the same length.
46. The photovoltaic device of claim 44, wherein:
5 the branched nanocrystals do not all have the same shape.
47. The photovoltaic device of claim 44, wherein:
the branched nanocrystals have 4 arms and have a tetrahedral symmetry.
48. The photovoltaic device of claim 47, wherein:
the branched nanocrystals are either CdSe or CdTe and are embedded in an amount of
10 about 90 wt%.
49. The photovoltaic device of claim 26, wherein:
the film has a thickness of from about 100 nm to about 350 nm.
50. The photovoltaic device of claim 49, wherein:
the film has a thickness of about 200 nm.
- 15 51. A process of making a polymeric thin film comprising,
washing surfactant coated semiconductor-nanocrystals with a solvent at least one
time, and
codissolving the washed semiconductor-nanocrystals and a semiconducting polymer
in a binary solvent mixture, and
20 depositing the mixture.
52. The process of making a polymeric thin film of claim 51, wherein:
at least a portion of the semiconductor-nanocrystals have an aspect ratio greater than
about 2.
53. The process of making a polymeric thin film of claim 51, wherein:
25 at least a portion of the semiconductor-nanocrystals have an aspect ratio greater than
about 5.
54. The process of making a polymeric thin film of claim 51, wherein:
at least a portion of the semiconductor-nanocrystals have an aspect ratio greater than
about 10.
- 30 55. The process of making a polymeric thin film of claim 51, wherein:
at least a portion of the semiconductor-nanocrystals have an aspect ratio of between
about 5 and about 50.
56. The process of making a polymeric thin film of claim 51, wherein:

at least a portion of the semiconductor-nanocrystals have an aspect ratio of between about 2 and about 10.

57. The process of making a polymeric thin film of claim 51, wherein:

the semiconducting conjugated polymer has between about 5 and about 99 wt% of semiconductor-nanocrystals embedded therein.

58. The process of making a polymeric thin film of claim 51, wherein:

the semiconducting conjugated polymer has between about 20 and 95 wt% semiconductor-nanocrystals embedded therein.

59. The process of making a polymeric thin film of claim 51, wherein:

the semiconducting conjugated polymer has between about 50 and 95 wt% semiconductor-nanocrystals embedded therein.

60. The process of making a polymeric thin film of claim 51, wherein:

the semiconducting conjugated polymer has about 90 wt% semiconductor-nanocrystals embedded therein.

61. The process of making a polymeric thin film of claim 51, wherein:

the semiconducting conjugated polymer is chosen from the group consisting of trans-polyacetylenes, polypyrroles, polythiophenes, polyanilines, poly(p-phenylene)s and poly(p-phenylene-vinylene)s, polyfluorenes, polyaromatic amines, poly(thienylene-vinylene)s and soluble derivatives thereof.

62. The process of making a polymeric thin film of claim 61, wherein:

the conjugated polymer is chosen from the group consisting of (poly(2-methoxy5-(2'-ethylhexyloxy)p-phenylenevinylene) (MEH-PPV) and poly(3-hexylthiophene, (P3HT).

63. The process of making a polymeric thin film of claim 51, wherein:

the semiconductor-nanocrystals comprise rods having a length of greater than about 20 nm.

64. The process of making a polymeric thin film of claim 51, wherein:

the semiconductor-nanocrystals comprise rods having a length of between about 20 nm and about 200 nm.

65. The process of making a polymeric thin film of claim 64, wherein:

the semiconductor-nanocrystals comprise rods having a length of between about 60 nm and about 110 nm.

66. The process of making a polymeric thin film of claim 51, wherein:

the semiconductor-nanocrystals comprise rods that are about 7 nm x 60 nm.

67. The process of making a polymeric thin film of claim 51, wherein:
the semiconductor-nanocrystals comprise a semiconductor selected from the group
consisting of Group II-VI, Group III-V, Group IV semiconductors and tertiary
chalcopyrites.
- 5 68. The process of making a polymeric thin film of claim 67, wherein:
the semiconductor-nanocrystals are selected from the group consisting of CdSe,
CdTe, InP, GaAs, CuInS₂, CuInSe₂, AlGaAs, InGaAs, Ge and Si.
69. The process of making a polymeric thin film of claim 51, wherein:
the semiconductor-nanocrystals are selected from the group consisting of CdSe and
10 CdTe.
70. The process of making a polymeric thin film of claim 51, wherein:
a portion of the semiconductor-nanocrystals are branched nanocrystals.
71. The process of making a polymeric thin film of claim 70, wherein:
a portion of the branched nanocrystals have at least two arms,
15 said arms are not all the same length.
72. The process of making a polymeric thin film of claim 70, wherein:
the branched nanocrystals do not all have the same shape.
73. The process of making a polymeric thin film of claim 70, wherein:
the branched nanocrystals have 4 arms and have a tetrahedral symmetry.
- 20 74. The process of making a polymeric thin film of claim 73, wherein:
the branched nanocrystals are either CdSe or CdTe and are embedded in an amount of
about 90 wt%.
75. The process of making a polymeric thin film of claim 51, wherein:
the film has a thickness of from about 100 nm to about 350 nm.
- 25 76. The process of making a polymeric thin film of claim 75, wherein:
the film has a thickness of about 200 nm.
77. The process of making a polymeric thin film of claim 51, wherein:
the binary solvent mixture comprises at least one solvent chosen from the group
consisting of pyridine, chloroform, toluene, xylenes, hexanes, water,
30 dichlorobenzene, methylene chloride, an alkylamine, where the alkyl chain may be
branched or unbranched and is between 2 and 20 carbons in length, butanol, methanol
and isopropanol.
78. The process of making a polymeric thin film of claim 51, wherein:
the concentration of the binary solvent mixture is between about 1 and about 15 vol%.

79. The process of making a polymeric thin film of claim 78, wherein:
the concentration of the binary solvent mixture is between about 4 and about 12 vol%.
80. The process of making a polymeric thin film of claim 79, wherein:
the concentration of the binary solvent mixture is about 8 vol%.
- 5 81. The process of making a polymeric thin film of claim 77, wherein:
the binary solvent mixture comprises pyridine in chloroform.
82. The process of making a polymeric thin film of claim 51, wherein:
the deposited thin film is heated at a temperature of from about 60 °C to about 200 °C.
83. The process of making a polymeric thin film of claim 82, wherein:
10 the deposited thin film is heated at a temperature of from about 80 °C to about 130 °C.
84. The process of making a polymeric thin film of claim 83, wherein:
the deposited thin film is heated at a temperature of about 120 °C.
85. A process of making a photoactive thin film, comprising:
dispersing semiconductor-nanocrystals in a semiconducting conjugated polymer to
15 provide a polymer-nanocrystal composite, and
depositing a thin film of said composite, such that the nanocrystals are embedded in
the polymer at greater than 5 wt%, wherein
at least a portion of said semiconductor-nanocrystals have an aspect ratio of greater
than 2.
- 20 86. The process of making a photoactive thin film of claim 85, wherein:
at least a portion of the semiconductor-nanocrystals have an aspect ratio greater than
about 5.
87. The process of making a photoactive thin film of claim 85, wherein:
at least a portion of the semiconductor-nanocrystals have an aspect ratio greater than
25 about 10.
88. The process of making a photoactive thin film of claim 85, wherein:
at least a portion of the semiconductor-nanocrystals have an aspect ratio of between
about 5 and about 50.
89. The process of making a photoactive thin film of claim 85, wherein:
30 at least a portion of the semiconductor-nanocrystals have an aspect ratio of between
about 2 and about 10.
90. The process of making a photoactive thin film of claim 85, wherein:
the semiconducting conjugated polymer has between about 5 and about 99 wt% of
semiconductor-nanocrystals embedded therein.

91. The process of making a photoactive thin film of claim 85, wherein:
the semiconducting conjugated polymer has between about 20 and 95 wt%
semiconductor-nanocrystals embedded therein.
92. The process of making a photoactive thin film of claim 85, wherein:
5 the semiconducting conjugated polymer has between about 50 and 95 wt%
semiconductor-nanocrystals embedded therein.
93. The process of making a photoactive thin film of claim 85, wherein:
the semiconducting conjugated polymer has about 90 wt% semiconductor-
nanocrystals embedded therein.
- 10 94. The process of making a photoactive thin film of claim 85, wherein:
the semiconducting conjugated polymer is chosen from the group consisting of trans-
polyacetylenes, polypyrroles, polythiophenes, polyanilines, poly(p-phenylene)s and
poly(p-phenylene-vinylene)s, polyfluorenes, polyaromatic amines, poly(thienylene-
vinylene)s and soluble derivatives thereof.
- 15 95. The process of making a photoactive thin film of claim 94, wherein:
the conjugated polymer is chosen from the group consisting of (poly(2-methoxy5-
(2'-ethylhexyloxy)p-phenylenevinylene) (MEH-PPV) and poly(3-hexylthiophene,
(P3HT).
96. The process of making a photoactive thin film of claim 85, wherein:
20 the semiconductor-nanocrystals comprise rods having a length of greater than about
20 nm.
97. The process of making a photoactive thin film of claim 85, wherein:
the semiconductor-nanocrystals comprise rods having a length of between about 20
nm and about 200 nm.
- 25 98. The process of making a photoactive thin film of claim 97, wherein:
the semiconductor-nanocrystals comprise rods having a length of between about 60
nm and about 110 nm.
99. The process of making a photoactive thin film of claim 85, wherein:
the semiconductor-nanocrystals comprise rods that are about 7 nm x 60 nm.
- 30 100. The process of making a photoactive thin film of claim 85, wherein:
the semiconductor-nanocrystals comprise a semiconductor selected from the group
consisting of Group II-VI, Group III-V, Group IV semiconductors and tertiary
chalcopyrites.
101. The process of making a photoactive thin film of claim 100, wherein:

the semiconductor-nanocrystals are selected from the group consisting of CdSe, CdTe, InP, GaAs, CuInS₂, CuInSe₂, AlGaAs, InGaAs, Ge and Si.

102. The process of making a photoactive thin film of claim 85, wherein:
the semiconductor-nanocrystals are selected from the group consisting of CdSe and CdTe.

103. The process of making a photoactive thin film of claim 85, wherein:
a portion of the semiconductor-nanocrystals are branched nanocrystals.

104. The process of making a photoactive thin film of claim 103, wherein:
a portion of the branched nanocrystals have at least two arms,
said arms are not all the same length.

105. The process of making a photoactive thin film of claim 103, wherein:
the branched nanocrystals do not all have the same shape.

106. The process of making a photoactive thin film of claim 103, wherein:
the branched nanocrystals have 4 arms and have a tetrahedral symmetry.

107. The process of making a photoactive thin film of claim 106, wherein:
the branched nanocrystals are either CdSe or CdTe and are embedded in an amount of about 90 wt%.

108. The process of making a photoactive thin film of claim 85, wherein:
the film has a thickness of from about 100 nm to about 350 nm.

109. The process of making a photoactive thin film of claim 108, wherein:
the film has a thickness of about 200 nm.

110. The process of making a photoactive thin film of claim 85, wherein:
the semiconductor-nanocrystals and the semiconducting polymer are codissolved in binary solvent mixture,
said binary solvent mixture comprises at least one solvent chosen from the group consisting of pyridine, chloroform, toluene, xylenes, hexanes, water, dichlorobenzene, THF, methylene chloride, an alkylamine, where the alkyl chain may be branched or unbranched and is between 2 and 20 carbons in length, butanol, methanol and isopropanol.

111. The process of making a photoactive thin film of claim 110, wherein:
the concentration of the binary solvent mixture is between about 1 and about 15 vol%.

112. The process of making a photoactive thin film of claim 111, wherein:
the concentration of the binary solvent mixture is between about 4 and about 12 vol%.

113. The process of making a photoactive thin film of claim 112, wherein:

the concentration of the binary solvent mixture is about 8 vol%.

114. The process of making a photoactive thin film of claim 110, wherein:
the binary solvent mixture comprises pyridine in chloroform.

115. The process of making a photoactive thin film of claim 85, wherein:
5 the deposited thin film is heated at a temperature of from about 60 °C to about 200 °C.

116. The process of making a photoactive thin film of claim 85, wherein:
the deposited thin film is heated at a temperature of from about 80 °C to about 130 °C.

117. The process of making a photoactive thin film of claim 85, wherein:
the deposited thin film is heated at a temperature of about 120 °C.

10 118. A photovoltaic device, comprising:
a conjugated conductive polymeric layer having semiconductor-nanocrystals
dispersed therein, and
said device having an power conversion efficiency greater than 1% at A.M. 1.5 global
illumination.

15 119. The photovoltaic device of claim 118, wherein:
the device has a power conversion efficiency of greater than 5%.

120. The photovoltaic device of claim 119, wherein:
the device has a power conversion efficiency of greater than 10%.

121. The photovoltaic device of claim 118, wherein:
20 the device has a power conversion efficiency of between about 1% and about 30%.

122. The photovoltaic device of claim 121, wherein:
the device has a power conversion efficiency of between about 2% and about 30%.

123. The photovoltaic device of claim 122, wherein:
the device has a power conversion efficiency of between about 5 % and about 15 %.

25 124. The photovoltaic device of claim 118, wherein:
the device has a power conversion efficiency of about 1.7%.

125. The photovoltaic device of claim 118, wherein:
at least a portion of the semiconductor-nanocrystals have an aspect ratio greater than
about 5.

30 126. The photovoltaic device of claim 118, wherein:
at least a portion of the semiconductor-nanocrystals have an aspect ratio greater than
about 10.

127. The photovoltaic device of claim 118, wherein:

at least a portion of the semiconductor-nanocrystals have an aspect ratio of between about 5 and about 50.

128. The photovoltaic device of claim 118, wherein:

at least a portion of the semiconductor-nanocrystals have an aspect ratio of between about 2 and about 10.

129. The photovoltaic device of claim 118, wherein:

the semiconducting conjugated polymer has between about 5 and about 99 wt% of semiconductor-nanocrystals embedded therein.

130. The photovoltaic device of claim 118, wherein:

the semiconducting conjugated polymer has between about 20 and 95 wt% semiconductor-nanocrystals embedded therein.

131. The photovoltaic device of claim 118, wherein:

the semiconducting conjugated polymer has between about 50 and 95 wt% semiconductor-nanocrystals embedded therein.

132. The photovoltaic device of claim 118, wherein:

the semiconducting conjugated polymer has about 90 wt% semiconductor-nanocrystals embedded therein.

133. The photovoltaic device of claim 118, wherein:

the semiconducting conjugated polymer is chosen from the group consisting of trans-polyacetylenes, polypyrroles, polythiophenes, polyanilines, poly(p-phenylene)s and poly(p-phenylene-vinylene)s, polyfluorenes, polyaromatic amines, poly(thienylene-vinylene)s and soluble derivatives thereof.

134. The photovoltaic device of claim 133, wherein:

the conjugated polymer is chosen from the group consisting of (poly(2-methoxy5-(2'-ethylhexyloxy)p-phenylenevinylene) (MEH-PPV) and poly(3-hexylthiophene, (P3HT).

135. The photovoltaic device of claim 118, wherein:

the semiconductor-nanocrystals comprise rods having a length of greater than about 20 nm.

136. The photovoltaic device of claim 118, wherein:

the semiconductor-nanocrystals comprise rods having a length of between about 20 nm and about 200 nm.

137. The photovoltaic device of claim 136, wherein:

the semiconductor-nanocrystals comprise rods having a length of between about 60 nm and about 110 nm.

138. The photovoltaic device of claim 118, wherein:

the semiconductor-nanocrystals comprise rods that are about 7 nm x 60 nm.

5 139. The photovoltaic device of claim 118, wherein:

the semiconductor-nanocrystals comprise a semiconductor selected from the group consisting of Group II-VI, Group III-V, Group IV semiconductors and tertiary chalcopyrites.

140. The photovoltaic device of claim 139, wherein:

10 the semiconductor-nanocrystals are selected from the group consisting of CdSe, CdTe, InP, GaAs, CuInS₂, CuInSe₂, AlGaAs, InGaAs, Ge and Si.

141. The photovoltaic device of claim 118, wherein:

the semiconductor-nanocrystals are selected from the group consisting of CdSe and CdTe.

15 142. The photovoltaic device of claim 118, wherein:

a portion of the semiconductor-nanocrystals are branched nanocrystals.

143. The photovoltaic device of claim 142, wherein:

a portion of the branched nanocrystals have at least two arms, said arms are not all the same length.

20 144. The photovoltaic device of claim 142, wherein:

the branched nanocrystals do not all have the same shape.

145. The photovoltaic device of claim 142, wherein:

the branched nanocrystals have 4 arms and have a tetrahedral symmetry.

146. The photovoltaic device of claim 145, wherein:

25 the branched nanocrystals are either CdSe or CdTe and are embedded in an amount of about 90 wt%.

147. The photovoltaic device of claim 118, wherein:

the film has a thickness of from about 100 nm to about 350 nm.

148. The photovoltaic device of claim 147, wherein:

30 the film has a thickness of about 200 nm.

149. A photovoltaic device, comprising:

a first planar electrode,

a thin film comprising a semiconducting conjugated polymer having semiconductor-nanocrystals embedded therein, the thin film being deposited on the first planar electrode, and

a second electrode opposite the first electrode, and

5 a hole injecting layer disposed between the thin film polymeric layer and the first planar electrode.

150. The photovoltaic device of claim 149, wherein:
the hole injecting layer comprises PEDOT:PSS.

151. The photovoltaic device of claim 149, wherein:
10 the first electrode comprises ITO and the second electrode comprises Al.

152. The photovoltaic device of claim 149, wherein:
at least a portion of the semiconductor-nanocrystals have an aspect ratio greater than about 5.

153. The photovoltaic device of claim 149, wherein:
15 at least a portion of the semiconductor-nanocrystals have an aspect ratio greater than about 10.

154. The photovoltaic device of claim 149, wherein:
at least a portion of the semiconductor-nanocrystals have an aspect ratio of between about 5 and about 50.

20 155. The photovoltaic device of claim 149, wherein:
at least a portion of the semiconductor-nanocrystals have an aspect ratio of between about 2 and about 10.

156. The photovoltaic device of claim 149, wherein:
the semiconducting conjugated polymer has between about 5 and about 99 wt% of
25 semiconductor-nanocrystals embedded therein.

157. The photovoltaic device of claim 149, wherein:
the semiconducting conjugated polymer has between about 20 and 95 wt%
semiconductor-nanocrystals embedded therein.

158. The photovoltaic device of claim 149, wherein:
30 the semiconducting conjugated polymer has between about 50 and 95 wt%
semiconductor-nanocrystals embedded therein.

159. The photovoltaic device of claim 149, wherein:
the semiconducting conjugated polymer has about 90 wt% semiconductor-nanocrystals embedded therein.

160. The photovoltaic device of claim 149, wherein:
the semiconducting conjugated polymer is chosen from the group consisting of trans-
polyacetylenes, polypyrroles, polythiophenes, polyanilines, poly(p-phenylene)s and
poly(p-phenylene-vinylene)s, polyfluorenes, polyaromatic amines, poly(thienylene-
vinylene)s and soluble derivatives thereof.

161. The photovoltaic device of claim 160, wherein:
the conjugated polymer is chosen from the group consisting of (poly(2-methoxy 5-
(2'-ethylhexyloxy)p-phenylenevinylene) (MEH-PPV) and poly(3-hexylthiophene,
(P3HT).

162. The photovoltaic device of claim 149, wherein:
the semiconductor-nanocrystals comprise rods having a length of greater than about
50 nm.

163. The photovoltaic device of claim 149, wherein:
the semiconductor-nanocrystals comprise rods having a length of between about 20
nm and about 200 nm.

164. The photovoltaic device of claim 163, wherein:
the semiconductor-nanocrystals comprise rods having a length of between about 60
nm and about 110 nm.

165. The photovoltaic device of claim 149, wherein:
the semiconductor-nanocrystals comprise rods that are about 7 nm x 60 nm.

166. The photovoltaic device of claim 149, wherein:
the semiconductor-nanocrystals comprise a semiconductor selected from the group
consisting of Group II-VI, Group III-V, Group IV semiconductors and tertiary
chalcopyrites.

167. The photovoltaic device of claim 166, wherein:
the semiconductor-nanocrystals are selected from the group consisting of CdSe,
CdTe, InP, GaAs, CuInS₂, CuInSe₂, AlGaAs, InGaAs, Ge and Si.

168. The photovoltaic device of claim 149, wherein:
the semiconductor-nanocrystals are selected from the group consisting of CdSe and
CdTe.

169. The photovoltaic device of claim 149, wherein:
a portion of the semiconductor-nanocrystals are branched nanocrystals.

170. The photovoltaic device of claim 169, wherein:
a portion of the branched nanocrystals have at least two arms,

said arms are not all the same length.

171. The photovoltaic device of claim 169, wherein:
the branched nanocrystals do not all have the same shape.
172. The photovoltaic device of claim 169, wherein:
the branched nanocrystals have 4 arms and have a tetrahedral symmetry.
173. The photovoltaic device of claim 172, wherein:
the branched nanocrystals are either CdSe or CdTe and are embedded in an amount of about 90 wt%.
174. The photovoltaic device of claim 149, wherein:
the film has a thickness of from about 100 nm to about 350 nm.
175. The photovoltaic device of claim 174, wherein:
the film has a thickness of about 200 nm.
176. A film, comprising:
a polymer having nanocrystals embedded therein.
177. A process of making a film comprising one or more of the following steps:
(a) washing nanocrystals with a solvent at least one time;
(b) dissolving the washed nanocrystals and a polymer in a solvent to yield a mixture; and
(c) depositing the mixture.
178. A photovoltaic device, comprising:
a polymeric layer having nanocrystals dispersed therein.
179. A photovoltaic device, comprising:
a first electrode,
a film comprising a polymer on the first electrode, and
a second electrode.